## **Electronic Supplementary Information**

## **Metal Intercalation Induced Magnetic Modulation**

in VS<sub>2</sub> Bilayer: A First Principles Study

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Fig. S1 Four kinds of possible positions of the intercalated TM atoms, (a) octahedral,(b) tetrahedral, (c-d) two hollow positions.

We systematically investigated possible intercalation sites for transition metals (TMs) in the van der Waals (vdW) gap of VS<sub>2</sub> bilayer. Using the 1Cr-VS<sub>2</sub> as an example, four distinct interstitial sites, including octahedral (A), tetrahedral (B), and two hollow positions (C and D), were evaluated (Fig. S1). Notably, D configuration spontaneously relaxed into the octahedral coordinated structure during geometry optimization. Therefore, we discussed total energies of A-C configurations.



**Fig. S2** Top and side views of TM-VS<sub>2</sub> at the intercalation concentrations of (a) 16.7%, (b) 25%, (c) 33.3%.



Fig. S3 The energy evolution during the AIMD simulations for 4Cr-VS<sub>2</sub> system. The AIMD simulations last for 10 ps at 500 K.



**Fig. S4** Schematics of four different magnetic structures for 4TM-VS<sub>2</sub> system: (a) FM, (b) AFM1, (c) AFM2, where pink arrows represent the spin up configurations and blue arrows represent the spin down configurations.



Fig. S5 The charge density difference of  $Cr-VS_2$  with concentrations of (a) 8.3%, (b) 16.7%, (c) 25%, (d) 33.3%. The isosurface value is set at 0.005 e/Å<sup>3</sup>. The blue and yellow regions represent charge depletion and accumulation, respectively.



Fig. S6 (a-d) The spin-polarized band structures and (e-f) PDOS of  $V_i_d$ ,  $V_d$ ,  $S_p$  orbitals of V-VS<sub>2</sub> systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively.



**Fig. S7** (a-d) The spin-polarized band structures and (e-f) PDOS of Mn\_d, V\_d, S\_p orbitals of Mn-VS<sub>2</sub> systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively.



**Fig. S8** (a-d) The spin-polarized band structures and (e-f) PDOS of Co\_d, V\_d, S\_p orbitals of Co-VS<sub>2</sub> systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively.



Fig. S9 Top and side views of spin density of V-VS<sub>2</sub> at the intercalation concentrations of (a) 8.3%, (b) 16.7%, (c) 25%, (d) 33.3%.



Fig. S10 Top and side views of spin density of  $Mn-VS_2$  at the intercalation concentrations of (a) 8.3%, (b) 16.7%, (c) 25%, (d) 33.3%.



Fig. S11 Top and side views of spin density of  $Co-VS_2$  at the intercalation concentrations of (a) 8.3%, (b) 16.7%, (c) 25%, (d) 33.3%.



Fig. S12 (a-d) The TDOS of V-VS<sub>2</sub> systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively. They correspond to ferromagnetic metal, ferromagnetic semiconductor, ferromagnetic metal, and antiferromagnetic metal, respectively.



Fig. S13 (a-d) The TDOS of  $Cr-VS_2$  systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively. They correspond to ferromagnetic half-metal, antiferromagnetic metal, ferromagnetic half-metal, and antiferromagnetic semiconductor, respectively.



Fig. S14 (a-d) The TDOS of  $Mn-VS_2$  systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively. They correspond to ferromagnetic half-metal, antiferromagnetic metal, ferromagnetic metal, and ferromagnetic semiconductor, respectively.



Fig. S15 (a-d) The TDOS of Co-VS<sub>2</sub> systems at the intercalation concentrations of 8.3%, 16.7%, 25%, 33.3%, respectively. They correspond to ferromagnetic metal, antiferromagnetic metal, ferromagnetic metal, and antiferromagnetic metal, respectively.

Table R1. Total energies (eV) of A-C configurations.

configuration	А	В	С
E(eV)	-427.52	-425.96	-427.21